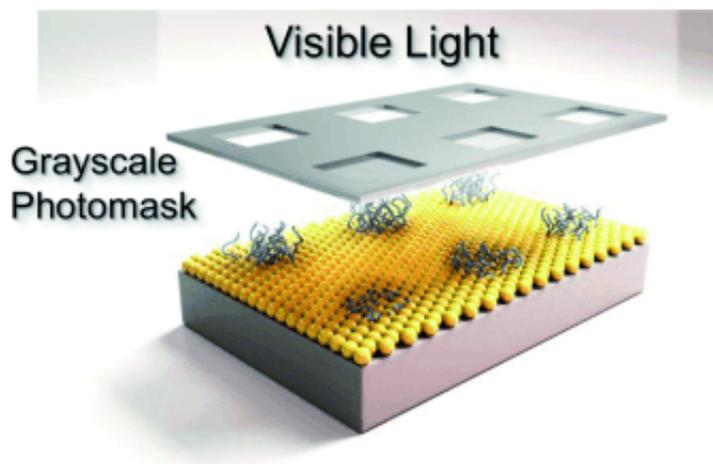


# Complex 3-D polymer brush nanostructures from photopolymerization

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(Phys.org) —Polymer brushes are polymers in which individual polymer chains stand side by side on a surface, causing the chains to stick out like bristles on a brush. In the journal *Angewandte Chemie*, American scientists have now presented a new simple method for making three-dimensional nanostructures in a controlled fashion from polymer brushes.

There are a wide variety of current and future applications for polymer brushes. For example, a coating of [polymer brushes](#) on a plastic surface such as an artificial heart valve or a [dialysis machine](#) can hinder the adsorption of proteins onto the surface. It can also be used in the

fabrication of next-generation microelectronic devices. Other areas of application include biocompatible coatings for implants, [chemical sensors](#), and new "intelligent" materials.

Although progress has been made with regard to new brush structures, current methods do not offer sufficient temporal and spatial control over the growth process. Usually, a self-organized [monolayer](#) of an initiator is assembled on a substrate and the [polymer chains](#) can grow out from there. In order to obtain specific patterns, the initiator must be applied to the substrate in a corresponding pattern—a complex undertaking that is not manufacturable and does not allow for the generation of complex three-dimensional structures.

Craig J. Hawker and a team from the University of California, Santa Barbara, and The [Dow Chemical](#) Company (Midland, Michigan) have developed a new method that allows for the formation of brushes on a uniform initiator layer with both spatial and temporal control. Their simple method is based on a light-activated [radical polymerization](#). The length of the bristles at any given location depends only on the duration and intensity of the local irradiation.

To form a specific structure, conventional photomasks can be used. These have openings in the areas to be irradiated and shield the other areas from the light. This allows for the formation of extensive patterns with submicrometer resolution in one step. All of this is made possible by a special iridium-based photocatalyst. It remains active for only a very short time after irradiation, so it cannot travel very far into nonirradiated areas while in its active state. It is even possible to use a grayscale photomask with continuously increasing opacity to produce graded patterns.

Another advantage of this new method is that newly incorporated monomers are always added to the chain adjacent to the initiator,

meaning that the initiator remains at the forward end of the growing chain. Because it is not destroyed as in other methods, and remains available at the right position, the polymerization can be stopped and restarted at any time. In this way the mask being used can be exchanged as often as desired. It is even possible to vary the monomer being used during the process. The complexity of accessible structures and applications is thus almost unlimited.

**More information:** Hawker, C. Fabrication of Complex Three-Dimensional Polymer Brush Nanostructures through Light-Mediated Living Radical Polymerization, *Angewandte Chemie International Edition*. [dx.doi.org/10.1002/anie.201301845](https://doi.org/10.1002/anie.201301845)

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